

LIGHT DEFLECTOR AND OPTICAL SWITCH INCLUDING SAME

BACKGROUND OF THE INVENTION

1. Field of the Invention

5 The present invention relates to optical devices. More particularly, the present invention relates to light deflectors composed of electro-optic photonic crystals and optical switches including the same.

2. Description of the Related Art

10 Photonic crystals are optical materials having periodic refractive index structures at a scale on the order of the wavelength of light. These crystals rely on a "photonic bandgap" to forbid the propagation of light in a predetermined wavelength band in a certain direction of the
15 crystal structure. That is, the photonic bandgap forbids the existence of light having wavelengths corresponding to the period of the crystal structure. Accordingly, photonic crystals are considered to have the potential to freely control light, and they are thus receiving attention as next-
20 generation electronic and optoelectronic materials.

 The existence of such photonic crystals was first proposed by S. John and E. Yablonovitch in 1987. Research into various experimental applications of these crystals is continuing.

25 The periodicity of the photonic crystal may be in one, two, or three directions. In order to produce photonic crystals with three-dimensional periodic structures, research has focused on methods including microfabrication techniques

and deposition techniques for semiconductor elements and devices. One promising research area relates to methods using particles with a size on the order of the wavelength of light as structural units, and with the particles stacked in
5 two-dimensional or three-dimensional arrangements.

Electro-optic effects occur when an electromagnetic field in the optical spectrum (i.e., light) interacts either with an electric field or matter influenced by an electric field. Optical switches have been known to include an optical
10 modulator using the electro-optical effect in LiNbO_3 or the like, for example, as disclosed in Japanese Unexamined Patent Application Publication No. 2002-196296. The use of optical switches in optical transmission systems has recently become widespread. In optical transmission systems, these switches
15 are required to have short switching times and small physical size. Unfortunately, conventional optical modulators are physically large in size, i.e., about several centimeters, since the length of the phase shifter is determined by the electro-optic coefficient.

20 Accordingly, what is needed is improved optical devices and switches that overcome the described shortcomings.

SUMMARY OF THE INVENTION

It is an object of the present invention to provide a
25 miniaturized light deflector which is capable of changing, at high speed, the refraction angle of light incident from outside so that the direction of transmission of the light can be changed.

It is another object of the present invention to provide an optical switch including the light deflector that can be miniaturized and in which the direction of transmitted light of a predetermined wavelength can be switched at high speed.

5 The present invention provides a method of forming photonic crystals using two-dimensional or three-dimensional periodic structures. Accordingly, a novel structure for a light deflector and an optical switch has been achieved that provides several advantages over the conventional structures.

10 In one aspect of the present invention, a light deflector comprises an electro-optic photonic crystal in which the refraction angle of light incident from outside can be controlled by controlling an electric field applied to the electro-optic photonic crystal so as to change the refractive
15 index of the material constituting the photonic crystal. Preferably, the change in the refraction angle in response to the change in the unit refractive index of the material is 10^3 degrees or more, and more preferably 10^4 degrees or more.

 The light deflector of the present invention uses the
20 superprism effect. This effect causes a light beam entering a photonic crystal to experience a large angular dispersion. This arises from the anisotropy of the photonic band structure, i.e., the strong anisotropy in the dispersion surface of the electro-optic photonic crystal. By changing
25 the magnitude of the electric field applied to the electro-optic photonic crystal, the refractive index of the material constituting the photonic crystal can be changed, and thereby the refraction angle of light incident from outside can also

be changed. Consequently, by controlling the electric field applied to the electro-optic photonic crystal, the refraction angle of light entering the electro-optic photonic crystal from outside can be controlled and hence the direction of
5 light emitted from the electro-optic photonic crystal can be controlled.

Furthermore, by using these techniques and structures, the refraction angle of light entering the electro-optic photonic crystal from outside can be changed rapidly in
10 response to the change in the electric field applied to the electro-optic photonic crystal.

Furthermore, since the electro-optic photonic crystal can be miniaturized, a miniature light deflector can be produced.

15 In the light deflector described in accordance with several embodiments of the present invention, preferably, the electro-optic photonic crystal includes a combination of a plurality of first dielectric members and a second dielectric member or a combination of a first dielectric member and a
20 plurality of second dielectric members, the first dielectric member comprising a material with a dielectric constant changeable by an electric field (a first material with dielectric constant changeable by an electric field) in which the dielectric constant is controlled by an electric field,
25 the second dielectric member having a different dielectric constant from that of the first dielectric member, wherein a plurality of first dielectric members or second dielectric members are periodically arrayed separately from each other,

thus forming a periodic structure (first periodic structure); the other dielectric member is disposed in the space of the periodic arrangement; and wherein the first dielectric member is composed of a material selected from the group consisting
5 of LiNbO_3 , LiTaO_3 , BaTiO_3 , GaAs, ZnO, $\text{NH}_4\text{H}_2\text{PO}_4$, and KH_2PO_4 .

In the light deflector having such a structure, when the magnitude of the electric field applied to the electro-optic photonic crystal is changed, the refractive index of the first dielectric member is changed, and consequently, the
10 refraction angle of light incident from outside is changed.

The first dielectric member is composed of a material that shows electro-optical characteristics in which the magnitude of the refractive index changes as the magnitude of the electric field applied is changed.

15 Air or the like is preferably used as the material for the second dielectric member. In the light deflector of the present invention, a plurality of regions in which air is selected for the material of the second dielectric members may be periodically arrayed separately from each other in the
20 first dielectric member.

Alternatively, in accordance with another embodiment of the present invention, the light deflector may comprise a plurality of first dielectric members periodically arrayed separately from each other. That is, the first dielectric
25 members may be arrayed, i.e., dispersed, in the second dielectric (air).

In the light deflector of the present invention, the direction of the electric field applied to the electro-optic

photonic crystal preferably corresponds to the direction with a higher electro-optic coefficient of the electro-optic photonic crystal, and more preferably corresponds to the direction with a higher electro-optic coefficient of the crystal constituting the first dielectric member. For example, in the case of a LiNbO_3 crystal, the electric field is preferably applied in the c-axis direction. In view of the shape, the electric field is preferably applied in the direction with a smaller thickness of the electro-optic photonic crystal.

In the light deflector of the present invention, preferably, the direction of the light incident from outside corresponds to a direction other than the direction of the normal line of the dispersion surface of the electro-optic photonic crystal. In other words, the direction of the incident light is other than the direction perpendicular to the dispersion surface of the electro-optic photonic crystal.

If the direction of the light incident from outside corresponds to the direction of the normal line of the dispersion surface of the electro-optic photonic crystal, the light entering the electro-optic photonic crystal is transmitted without being refracted, resulting in no change to the refraction angle.

The light deflector of the present invention may be provided with electrodes for applying an electric field to the electro-optic photonic crystal.

The light deflector of the present invention may be provided with a variable power unit which is capable of

applying a DC or AC electric field to the electro-optic photonic crystal and in which the magnitude of the voltage (electric field) applied can be varied.

Furthermore, the light deflector of the present invention may be provided with a unit for introducing light into the electro-optic photonic crystal.

In another aspect of the present invention, an optical switch includes the light deflector of the present invention and a photonic crystal waveguide, the photonic crystal waveguide having a photonic bandgap corresponding to light of a predetermined wavelength and also having at least one waveguide which passes the light of the predetermined wavelength.

The optical switch of the present invention is configured such that the light entering the electro-optic photonic crystal constituting the light deflector is selected (i.e., predetermined) to have a wavelength band corresponding to those forbidden by the photonic bandgap.

In the optical switch having such a structure, when the magnitude of the electric field applied to the electro-optic photonic crystal constituting the light deflector is changed, the refraction angle of light of a predetermined wavelength entering the electro-optic photonic crystal is changed, and hence the direction of light of the predetermined wavelength emitted from the electro-optic photonic crystal (outgoing light) is changed. Consequently, the outgoing light is transmitted through a waveguide which is present in the direction of the emitted light of the predetermined

wavelength, that is, one waveguide from the provided photonic crystal waveguides. Therefore, the direction in which the transmitted light of the predetermined wavelength passes through can be switched at high speed. Since the photonic crystal waveguide can also be miniaturized along with the electro-optic photonic crystal, it is possible to produce a miniature optical switch.

The photonic crystal waveguide provided in the optical switch of the present invention includes a third dielectric member composed of a second material with a dielectric constant changeable by an electric field in which the dielectric constant is controlled by an electric field and a fourth dielectric member having a different dielectric constant from that of the third dielectric member, wherein a plurality of third dielectric members or fourth dielectric members are periodically arrayed separately from each other to form a periodic structure (second periodic structure); and the other dielectric member is disposed in the space of the periodic arrangement. The photonic crystal waveguide also includes a region in which the periodic structure is omitted at least in part, the region being a waveguide, and a plurality of waveguides may be provided in response to the refraction angles of light entering the light deflector. The periodic structure has a photonic bandgap for light of a predetermined wavelength.

In the photonic crystal structure, by partially omitting the periodic structure in which a plurality of third dielectric members or fourth dielectric members are

periodically arrayed separately from each other, it is possible to introduce a defect corresponding to the portion omitted. That is, a localized state appears in the photonic bandgap due to the defect, and light is trapped therein. By continuously connecting defects, it is possible to guide light along the defects, and a waveguide can thus be formed along the portions in which the periodic structure is omitted. Consequently, it is possible to provide a photonic crystal waveguide in which light can be guided along the waveguide.

10 By forming a plurality of waveguides corresponding to the refraction angles of light of a predetermined wavelength entering the light deflector, when the magnitude of the electric field applied to the electro-optic photonic crystal is changed and the refraction angle of light of the predetermined wavelength entering the electro-optic photonic crystal is changed accordingly, thus changing the direction of the light of the predetermined wavelength emitted from the electro-optic photonic crystal (outgoing light), the outgoing light is transmitted through the waveguide corresponding to the refraction angle of light of the predetermined wavelength, among the plurality of waveguides provided in the photonic crystal. Therefore, the direction of emission of the transmitted light of the predetermined wavelength can be switched at high speed.

25 The third dielectric member used in the photonic crystal waveguide may be composed of a material selected from the group consisting of Si, GaP, GaAs, InP, ZnTe, Ge, LiNbO₃, LiTaO₃, BaTiO₃, ZnO, NH₄H₂PO₄, and KH₂PO₄. By forming the

third dielectric member using such a material, it is possible to utilize a high dielectric constant and a high refractive index.

The fourth dielectric member used in the photonic crystal waveguide may be composed of a material selected from the group consisting of air and liquid crystal.

In the photonic crystal waveguide, the array period of the periodic structure of the dielectric members preferably corresponds to a fraction of the wavelength of predetermined light. By properly designing the period, the lattice shape of the array, the refractive indexes of the dielectric members, the shape, etc., it is possible to control the photonic bandgap.

15 BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a plan view which schematically shows a structure of an optical switch in accordance with an embodiment of the present invention;

FIG. 2 is a sectional view of the optical switch shown in FIG. 1;

FIG. 3 is an assembly view of one of the substrates constituting a photonic crystal waveguide provided in the optical switch shown in FIG. 1; and

FIG. 4 is an assembly view of the other substrate constituting the photonic crystal waveguide provided in the optical switch shown in FIG. 1.

DESCRIPTION OF THE PREFERRED EMBODIMENTS

The preferred embodiments of the present invention will be described in detail with reference to the drawings.

It is to be understood that the present invention is not limited to the embodiments described below. In order to
5 facilitate the description in the drawings, the individual components are shown on different scales.

FIG. 1 is a plan view which schematically shows a structure of an optical switch in accordance with an embodiment of the present invention, and FIG. 2 is a
10 sectional view of the optical switch shown in FIG. 1.

The optical switch in this embodiment includes a light deflector A and a photonic crystal waveguide B.

The light deflector A uses the superprism effect to cause the incident light entering the photonic crystal to
15 experience a large angular dispersion, i.e., the refraction angle of incident light is sensitively changed. This arises from the anisotropy of the photonic band structure, i.e., the strong anisotropy in the wave-vector surface of the electro-optic photonic crystal.

20 The light deflector A is composed of an electro-optic photonic crystal which includes conductive substrates 1 and 2 which are placed substantially parallel to each other with a distance therebetween; a transparent sealing member 5 interposed between the peripheries of the substrates 1 and 2
25 and surrounding the void between the substrates 1 and 2; a plurality of cylinders (first dielectric members) 3 which are interposed between the substrates 1 and 2 and stand at an interval corresponding to a fraction of the wavelength of

light; and air (a second dielectric member) 6 filled in the space surrounded by the substrates 1 and 2 and the sealing member 5 and around the cylinders 3. That is, in the electro-optic photonic crystal, a plurality of cylinders 3 are periodically arrayed separately from each other, and the region in which the air 6 is present is disposed in the space of the periodic arrangement.

A light source 4, such as a laser emission device, which is capable of emitting light of a desired wavelength is placed in the exterior of the transparent sealing member 5, separately from the electro-optic photonic crystal. Light L of a predetermined wavelength (e.g., 1,550 nm or 1,310 nm) is emitted from the light source 4 so as to be incident on the void between the substrates 1 and 2 constituting the electro-optic photonic crystal through the transparent sealing member 5.

In the optical switch of this embodiment, as the incident light L entering the electro-optic photonic crystal from outside, light in a wavelength band whose existence is forbidden by the photonic bandgap of the photonic crystal waveguide B is used. That is, the wavelength of the light selected falls within the range of frequencies for which propagation is forbidden in the material. For example, if the light L of a predetermined wavelength transmitted to the optical switch is light of a wavelength of 1,550 nm, the photonic bandgap is about 100 nm (1.45 μm to 1.55 μm).

The substrates 1 and 2 are composed of a high-dielectric constant material (first high-dielectric constant material),

such as ion-doped, highly conductive LiNbO_3 . These materials are also known as high-k materials. Oxide layers 7 and 8 are disposed on the opposing surfaces of the substrates 1 and 2, the oxide layers 7 and 8 being formed by surface oxidation or the like of the LiNbO_3 substrates. The material for the substrates 1 and 2 is a material with a dielectric constant changeable (i.e., controlled) by an electric field (a first material with dielectric constant changeable by electric field). This material also shows electro-optic characteristics in which the refractive index changes as the magnitude of an electric field applied is changed (hereinafter also referred to as an "electro-optic material"). Therefore, the substrates 1 and 2 may be composed of LiTaO_3 , BaTiO_3 , GaAs, ZnO, $\text{NH}_4\text{H}_2\text{PO}_4$, KH_2PO_4 , or the like besides LiNbO_3 (refractive index $n = 2.2$ in the normal state, i.e., in the absence of an applied electric field).

The refractive indexes of these materials alternative to LiNbO_3 are as follows: $\text{LiTaO}_3 = 2.2$, $\text{BaTiO}_3 = 2.4$, GaAs = 3.4, ZnO = 2.0, $\text{NH}_4\text{H}_2\text{PO}_4 = 1.5$, and $\text{KH}_2\text{PO}_4 = 1.5$ (in the normal state, i.e., in the absence of an applied electric field). Each material has a high dielectric constant and shows electro-optic characteristics in which the refractive index changes as the magnitude of an electric field applied is changed.

In the electro-optic photonic crystal, the refraction angle of light incident from outside changes in a manner sensitive to changes in the magnitude of an applied electric field. The electro-optic photonic crystal does not

necessarily have a bandgap. Further, the difference in refractive index between the cylinder (first dielectric member) 3 and the second dielectric member 6 may be small.

The second dielectric member 6 must have a different dielectric constant from that of the first dielectric member 3. For example, the second dielectric member 6 may be composed of a liquid crystal and the first dielectric composed of air. The refractive index of air is 1 both in the normal state (in the absence of an applied electric field) and in the presence of an applied electric field. In contrast, with respect to a liquid crystal, the dielectric constant in the presence of an applied electric field is different from the dielectric constant in the absence of an applied electric field, more noticeably so than with air. Specifically, it is possible to use a nematic liquid crystal with a dielectric constant of 2 to 3. If an electric field with an intensity of about 1 MV/cm is applied to such a nematic liquid crystal with a refractive index of 1.53 in the normal state, the refractive index is changed to 1.6.

The cylinders 3, i.e., the first dielectric members, are preferably formed by etching or the like of one of the substrates 1 and 2. In this embodiment, a plurality of cylinders 3 are formed at an interval corresponding to a fraction of the wavelength of predetermined light L emitted from the light source 4. A set of the plurality of cylinders 3 constitutes a periodic structure (first periodic structure) 3A.

In particular, the distance P_1 between the centers of

two adjacent cylinders 3 is preferably set at about a fraction of the wavelength λ of the predetermined light L (0.2λ to 0.8λ), and the diameter D_1 of the cylinder 3 is set at about a fraction of the wavelength λ of the predetermined light L (0.2λ to 0.8λ wherein $D_1 < P_1$). More specifically, when light with a wavelength of 1,550 nm is used, for example, the distance P_1 between the centers of two adjacent cylinders 3 may be selected from the range of 0.3 to 1.1 μm , and the diameter D_1 of the cylinder 3 may be selected from the range of 0.14 to 0.5 μm .

GaAs may be used as a material for the first high-k dielectric material constituting the first dielectric members 3, since GaAs is used as a semiconductor material and can be imparted with conductive properties by ion doping or the like. Furthermore, GaAs may be used to form the electrodes for applying an electric field to the electro-optic photonic crystal. When LiNbO_3 or the like is used as the first high-k dielectric material constituting the first dielectric members 3, electrodes are provided on the respective outer surfaces of the substrates 1 and 2. These electrodes are used for applying an electric field to the electro-optic photonic crystal.

A variable power unit 10 is illustrated connected to the substrates 1 and 2 by interconnect lines 9A and 9B, respectively. By turning on a switch 10a which is built in the interconnect line 9B, an alternating current (electric field) can be applied to the plurality of cylinders 3 interposed between the substrates 1 and 2. By turning off

the switch 10a, the application of the alternating current (electric field) can be stopped. The variable power unit 10 is also preferably constructed so that the magnitude of the voltage (electric field) applied to the substrates 11 and 12 can be changed.

The following equation (1) relates to the characteristics of the light deflector A in this embodiment.

$$\begin{aligned}\Delta\theta_r &= (\partial\theta_r/\partial n)\Delta n \\ &= (\partial\theta_r/\partial n) \times (1/2) \times \gamma_{33}n^3E \quad \dots (1)\end{aligned}$$

where n is the refractive index of the electro-optic material (the refractive index of the first dielectric member 3 in this embodiment), θ_r is the refraction angle of light entering the electro-optic photonic crystal from outside, γ_{33} is the electro-optic coefficient (Pockels coefficient), E is the intensity of an electric field applied to the electro-optic material (the first dielectric member 3 in this embodiment), and $(1/2) \times \gamma_{33}n^3E$ represents a difference in refractive index due to the electro-optic effect.

In this embodiment, since the light deflector A is composed of the electro-optic photonic crystal, if the magnitude of the electric field applied is changed, the refractive index of the plurality of cylinders (first dielectric members) 3 changes, resulting in a change in the refractive index of the entire electro-optic photonic crystal. Consequently, the refraction angle of light L entering the electro-optic photonic crystal from outside can be changed. The change in the refraction angle is preferably 10^3 degrees or more and more preferably 10^4 degrees or more, i.e., $\partial\theta_r/\partial n$

is 10^3 degrees or more and more preferably 10^4 degrees or more per unit change in refractive index.

If $\partial\theta_r/\partial n$ is less than 10^3 degrees, the size of the device becomes about 1 cm or more, which is undesirable.

5 In the case of LiNbO_3 , if an electric field of 10 V/1 μm is applied, the refractive index of the first dielectric member 3 changes by 10^{-3} , and therefore the refraction angle of light entering the electro-optic photonic crystal from outside is changed by 1 degree. For example, at an applied
10 voltage of 2 V, the refraction angle of light entering the electro-optic photonic crystal from outside is changed by 2 degrees. Consequently, the position of the electro-optic photonic crystal from which light is emitted is changed by on the order of micrometers (about 17 μm). Therefore, in the
15 presence of an applied voltage, it is possible to set the position from which light is emitted adequately apart from the position from which light is emitted in the absence of an applied electric field. Thus, the direction of light emitted from the electro-optic photonic crystal can be changed and
20 two states can be shown to exist.

In accordance with this embodiment, the direction of the electric field applied to the electro-optic photonic crystal preferably corresponds to the direction with a higher electro-optic coefficient of the electro-optic photonic
25 crystal, and more preferably corresponds to the direction with a higher electro-optic coefficient of the crystal constituting the first dielectric member 3. For example, when the first dielectric member 3 is composed of a LiNbO_3

crystal, the electric field is preferably applied in the c-axis direction of the crystal.

In view of the shape, the electric field is preferably applied in the direction with a smaller thickness of the
5 electro-optic photonic crystal.

In this embodiment, the direction of the incident light L entering the electro-optic photonic crystal from outside corresponds to a direction other than the direction of the normal line of the dispersion surface (wave-vector surface)
10 of the electro-optic photonic crystal. That is, the direction is other than the direction perpendicular to the dispersion surface of the electro-optic photonic crystal. For example, the incident direction of light L may be inclined at any of several angles with respect to the
15 direction of the normal line of the dispersion surface (wave-vector surface).

On the other hand, if the incident direction of light entering the electro-optic photonic crystal corresponds to the direction of the normal line of the dispersion surface of
20 the electro-optic crystal, the light entering the electro-optic photonic crystal is transmitted without being refracted, resulting in no change to the refraction angle.

The operation of the light deflector A according to this embodiment will be described below.

25 When an electric field is not applied to the light deflector A, the refractive index of the first dielectric member 3 is the same as that in the normal state. As shown in FIG. 1, when light L of a predetermined wavelength from

the light source 4 is incident on the electro-optic photonic crystal in the absence of an applied electric field, the light L is refracted at a normal refraction angle, and light L_1 refracted at the normal refraction angle is emitted toward
5 the photonic crystal waveguide B.

When an electric field is applied to the light deflector A, the first dielectric member 3 has a refractive index that is different from the normal refractive index. As shown in FIG. 1, when light L of a predetermined wavelength from the
10 light source 4 is incident on the electro-optic photonic crystal in the presence of an applied electric field, the light L is refracted at a refraction angle that is different from the normal refraction angle, and light L_2 refracted at the refraction angle that is different from the normal
15 refraction angle is emitted toward the photonic crystal waveguide B. Additionally, the difference in refraction angle between the light L_1 and the light L_2 corresponds to $\Delta\theta_r$ and the difference in the refractive index of the first dielectric member (electro-optic member) 3 between the two
20 states, i.e., in the presence of an applied electric field and in the absence of an applied electric field, corresponds to Δn .

Consequently, the distance P between the position of the electro-optic photonic crystal from which light is emitted in
25 the presence of an applied electric field and the position of the electro-optic photonic crystal from which light is emitted in the absence of an applied electric field is sufficiently large, and moreover, the direction of light

emitted from the electro-optic photonic crystal can be changed.

In the light deflector A of this embodiment, by controlling the electric field applied to the electro-optic photonic crystal, the refraction angle of light entering the electro-optic photonic crystal from outside can be controlled, and the direction of light emitted from the electro-optic photonic crystal can be controlled. The refraction angle of light entering the electro-optic photonic crystal from outside can be rapidly changed in response to the change in the electric field applied to the electro-optic photonic crystal. Since the electro-optic photonic crystal can be miniaturized, a miniature light deflector can be produced.

The photonic crystal waveguide B has a photonic bandgap for light L of a predetermined wavelength.

The photonic crystal waveguide B includes conductive substrates 11 and 12 which are placed substantially parallel to each other with a distance therebetween; a transparent sealing member 15 interposed between the peripheries of the substrates 11 and 12 and surrounding the void between the substrates 11 and 12; a plurality of cylinders (third dielectric members) 13 which are interposed between the substrates 11 and 12 and stand at an interval corresponding to a fraction of the wavelength of light; air (refractive index $n = 1$) as a fourth dielectric member 16 filled in the space surrounded by the substrates 11 and 12 and the sealing member 15 and around the cylinders 13; and a plurality of waveguides 22 interposed between the substrates 11 and 12.

That is, in the photonic crystal waveguide B, a plurality of third dielectric members 13 are periodically arrayed separately from each other to form a periodic structure (second periodic structure) 13A, and the region in which the
5 air 16 is present is disposed in the space of the periodic arrangement. The second periodic structure 13A is partially omitted, and regions in which the second periodic structure 13A is omitted correspond to the waveguides 22.

The substrates 11 and 12 are composed of a high-
10 dielectric constant material (second high-dielectric constant material), such as Si, and oxide layers 17 and 18 are disposed on the opposing surfaces of the substrates 11 and 12, the oxide layers 17 and 18 being formed by surface oxidation or the like of the Si substrates. The substrates 11 and 12
15 must be composed of a high-dielectric constant material. Therefore, the substrates 11 and 12 may be composed of a second high-dielectric material with conductivity values different from Si (refractive index $n = 3.5$), for example materials such as GaP, GaAs, InP, ZnTe, Ge, LiNbO₃, LiTaO₃,
20 BaTiO₃, ZnO, NH₄H₂PO₄, or KH₂PO₄.

The refractive indexes of these materials alternative to Si are as follows: GaP = 3.45, GaAs = 3.4, InP = 3.29, ZnTe = 9.61, Ge = 4.1, LiNbO₃ = 2.2, LiTaO₃ = 2.2, BaTiO₃ = 2.4, ZnO = 2.0, NH₄H₂PO₄ = 1.5, and KH₂PO₄ = 1.5. Each material has a
25 high dielectric constant. In the photonic crystal waveguide B, the difference between the refractive index of the cylinders (third dielectric members) 13 which are composed of a second material with a dielectric constant changeable by an

electric field in which the dielectric constant is controlled by an electric field and the refractive index of the fourth dielectric member 16 is preferably large because the bandgap can be increased. Therefore, the fourth dielectric member 16 is preferably composed of a material with a refractive index of about 3 or more.

The cylinders 13 which are the third dielectric members are formed by etching or the like of one of the substrates 11 and 12. In this embodiment, a plurality of cylinders 13 are formed at an interval corresponding to a fraction of the wavelength of predetermined light emitted from the light source 4, and a group of the plurality of cylinders 13 constitutes the periodic structure (second periodic structure) 13A.

In this embodiment, when transmission (passing) and interruption of light of a predetermined wavelength are attempted to be controlled, the distance P_2 between the centers of two adjacent cylinders 13 is set at about a fraction of the wavelength λ of the predetermined light (0.2λ to 0.8λ), and the diameter D_2 of the cylinder 13 is set at about a fraction of the wavelength λ of the predetermined light L (0.2λ to 0.8λ wherein $D_2 < P_2$). More specifically, when light with a wavelength of 1,550 nm is used to control the transmission (passing) and interruption of the light of this wavelength, for example, the distance P_2 between the centers of two adjacent cylinders 13 may preferably be selected from the range of 0.3 to 1.1 μm , and the diameter D_2 of the cylinder 13 may preferably be selected from the range

of 0.14 to 0.5 μm .

The fourth dielectric member 16 may be composed of a liquid crystal instead of air. For example, a nematic liquid crystal with a dielectric constant of 2 to 3 may be used.

5 In the photonic crystal waveguide B, as shown in FIG. 1, regions in which parts of the cylinders 13 are linearly omitted are provided in the second periodic structure 13A. In other words, a plurality of regions in which the cylinders 13 are partially omitted extending from the light deflector A
10 side to the opposite side are provided to form a plurality of waveguides 22 (two waveguides in this embodiment).

The plurality of waveguides 22 are formed corresponding to the refraction angles of light L of a predetermined wavelength entering the light deflector A from outside, i.e.,
15 corresponding to the directions of light of a predetermined wavelength emitted from the light deflector A. A waveguide 22a is provided corresponding to the refraction angle of light L with a predetermined wavelength entering the light deflector A in the absence of an applied electric field
20 (corresponding to light L_1 of the predetermined wavelength emitted from the light deflector A in the absence of an applied electric field). A waveguide 22b is provided corresponding to the refraction angle of light L of a predetermined wavelength entering the light deflector A from
25 outside (corresponding to light L_2 of the predetermined wavelength emitted from the light deflector A in the presence of an applied electric field).

In the optical switch shown in FIG. 1, when

predetermined light L, for example, with a wavelength of 1,550 nm is allowed to enter the photonic crystal waveguide B (at a section other than the portions in which defects are introduced into the periodic structure 13A), a photonic
5 bandgap for light is generated because the periodic structure 13A formed by the plurality of cylinders 13 and air 16 filled in the space between the cylinders 13 constitute a photonic crystal. Herein, the photonic bandgap corresponds to a frequency band in which light of predetermined frequencies is
10 not transmitted.

For example, when the wavelength of predetermined light L entering the photonic crystal waveguide B is 1,550 nm, the photonic bandgap is 1,450 to 1,550 nm (0.86 to 0.8 eV). Consequently, the region of the periodic structure 13A having
15 the periodic arrangement of the cylinders 13 reflects and does not transmit light with wavelengths in the range of 1,450 to 1,550 nm.

In contrast, if predetermined light L with a wavelength of 1,550 nm is allowed to enter the waveguide 22 at a section
20 in which the cylinders 13 are omitted, light can pass through the waveguide 22, with the light of that wavelength blocked in the other regions of the waveguide 22. Consequently, light is transmitted along (passes through) the waveguide 22 in a controlled manner. That is, in the periodic structure 13A,
25 omission of the cylinders 13 in part of the structure 13A is equivalent to introduction of defects into the periodic structure 13A. In the defects, there is no influence from the photonic bandgap.

An example of the operation of the optical switch according to this embodiment will be described below.

When light L of a predetermined wavelength from the light source 4 is incident on the light deflector A in the absence of an applied electric field, the light L is refracted at a normal refraction angle, and light L_1 refracted at the normal refraction angle is emitted toward the photonic crystal waveguide B. The light L_1 passes through the waveguide 22a and emitted from the emission side of the photonic crystal waveguide B (opposite to the light deflector A side).

When light L of a predetermined wavelength from the light source 4 is incident on the light deflector A in the presence of an applied electric field, the light L is refracted at a refraction angle which is different from the normal refraction angle by $\Delta\theta_r$, and light L_2 refracted at the refraction angle which is different from the normal refraction angle is emitted toward the photonic crystal waveguide B. That is, the light L_2 passes through the waveguide 22b and emitted from the emission side of the photonic crystal waveguide B (opposite to the light deflector A side) at a position different from the position at which the light L_1 is emitted.

Even if light diverts from the waveguide 22 in the middle of the waveguide 22, the light is reflected by the periodic structure 13A, i.e., the region composed of the cylinders 13 surrounding the waveguide 22. Consequently, the light is transmitted along the waveguide 22 without fail and

is emitted from the emission side of the photonic crystal waveguide B (opposite to the light deflector A side) without fail.

In order to fabricate the photonic crystal waveguide B provided on the optical switch shown in FIG. 1, for example, a surface of the substrate 11 composed of Si is subjected to oxidation treatment to form the oxide layer 17. Next, for example, as shown in FIG. 3, the transparent sealing member is placed along the periphery of the oxide layer 17 on the substrate 11.

A surface of the other substrate 12 composed of Si is etched by chemical etching or physical etching, such as ion beam etching, and many cylinders (third dielectric members) 13 may thereby be formed on the substrate 12 as shown in FIG. 4. By avoiding the formation of the cylinders in the regions to which defects are introduced, the waveguides 22 are formed.

In order to perform chemical etching, a resist is applied onto the surface of the substrate 12, and drawing by lithography or other conventional writing procedures is performed by an exposure apparatus or the like so as to correspond to the periodic structure of the cylinders. The resist in the drawn regions only are removed by dissolution with a developer to form many holes. Immersion into an etchant is performed using the holes. In order to perform physical etching, the Si substrate is etched by SF_6 plasma or the like to form a plurality of cylinders 13.

Alternatively, in order to form perpendicular cylinders, the following method may be employed.

First, a resist composed of poly(methyl methacrylate) (PMMA) or the like which is sensitive to electron beam exposure is applied onto a Si wafer, and a periodic structure is drawn thereon by an electron beam. The PMMA resist in the drawn regions are removed by dissolution with a developer to form windows. Iron atoms with a thickness of about 1 nm are vapor-deposited, and then the PMMA resist is removed by a lift-off method. Thereby, iron atoms aggregate on the surface of the substrate, and iron clusters can be formed only on the regions in which windows are opened corresponding to the regions drawn by the electron beam. Next, by etching the substrate using SF_6 plasma gas under appropriate etching conditions, such as the sample temperature and gas pressure, the iron clusters and their peripheries only remain without being etched. Many Si cylinders with a uniform size can thus be fabricated. The iron clusters themselves do not function as etching masks, but function as nuclei for forming etching masks with a uniform size by condensing the reaction products, such as S_xF_x , from the plasma. As described above, iron clusters are capable of forming masks with high etching resistance, and by using such a function, it is possible to fabricate Si cylinders with a uniform size.

By using this method, it is possible to reliably form a periodic structure in which many Si cylinders with a diameter of 40 nm and a height of 1 μm are arrayed at an interval of about 270 nm at the apexes of tetragonal lattices or at the apexes of trigonal lattices when viewed in plan.

The light deflector A provided on the optical switch

shown in FIG. 1 can be fabricated as in the photonic crystal waveguide B described above except that defects are not introduced into the periodic structure and that the first high-dielectric material is used for the two substrates.

5 In the optical switch of this embodiment, if a plurality of waveguides 22 corresponding to the refraction angles of light L with a predetermined wavelength entering the light deflector A are provided in the photonic crystal waveguide B in advance, when the refraction angle of the light L of the
10 predetermined wavelength entering the electro-optic photonic crystal is changed in response to a change in the magnitude of an electric field applied to the electro-optic photonic crystal and the direction of light of the predetermined
 wavelength emitted from the electro-optic photonic crystal
15 (outgoing light) is changed, the outgoing light is transmitted (passes) through the waveguide 22 corresponding to the refraction angle of the light of the predetermined wavelength, among a plurality of waveguides 22 provided in the photonic crystal waveguide B. Therefore, the direction
20 of emission of the transmitted light of the predetermined wavelength can be switched at high speed. For example, the switching rate can be set at μ sec or more. Since the photonic crystal waveguide B can also be miniaturized along with the electro-optic photonic crystal constituting the
25 light deflector A, a miniature optical switch can be produced, for example, at a size of several millimeters.

 Because of the structure described above, the portion of the sealing member 5 or sealing member 15 on which light is

incident must be translucent or transparent, and the portion from which light is emitted must be translucent or transparent. Therefore, preferably, the entire sealing member 5 or sealing member 15 is transparent.

5 In the electro-optic photonic crystal having the structure shown in FIG. 1, only a plurality of cylinders 3 must be composed of the first high-dielectric constant material. It is not necessary to form the entire substrates 1 and 2 using the first high-dielectric material. That is,
10 the substrates 1 and 2 may be composed of other commonly used materials leaving only the cylinders 3 to be composed of the first high dielectric constant material. With respect to the photonic crystal waveguide B, the substrates 11 and 12 may be composed of a commonly used material other than the second
15 high-dielectric constant material, leaving only the cylinders 13 to be composed of the second high-dielectric constant material. In other words, only the cylinders 13 need to be composed of the second high dielectric constant material.

In the electro-optic photonic crystal having the
20 structure shown in FIG. 1, metal electrodes or electrode layers, such as transparent electrode layers may be separately formed on the air 6 sides of the substrates 1 and 2 so that an electric field can be applied to the periodic structure 3A from the electrode layers. In such a case, it
25 is not always necessary to form the substrates 1 and 2 using a conductor, such as ion-doped LiNbO_3 . Consequently, a structure may be employed in which the substrates 1 and 2 are composed of an insulator which is not a high-dielectric

constant material; electrode layers, such as indium tin oxide (ITO) layers or metal electrode layers, are separately formed on the opposing surfaces of the insulating substrates; and a plurality of cylinders 3 composed of the first high-dielectric material are interposed between the insulating substrates.

In this embodiment, since the periodic structures provided on the electro-optic photonic crystal and the photonic crystal waveguide are composed of sets of cylinders composed of high-dielectric materials, two-dimensional periodic structures are formed. The periodic structures may be three-dimensional. For example, instead of a structure in which simple cylinders are arrayed, a three-dimensional structure in which cylinders are assembled into a lattice-shape may be acceptable. The three-dimensional structure may be assembled into various shapes, such as a branched three-dimensional shape, a network three-dimensional shape, or a three-dimensional structure in which amorphous dielectric members are assembled.

In the embodiment described above, the electro-optic photonic crystal constituting the light deflector A has the first periodic structure 3A in which the first dielectric members 3 are separated from each other and the second dielectric member 6 is disposed in the space in the peripheries of the first dielectric members 3 and surrounded by the substrates 1 and 2 and the sealing member 5. Alternatively, the first periodic structure may include a main body composed of the first dielectric member disposed in

the region surrounded by the substrates 1 and 2 and the sealing member 5, and wherein a plurality of holes are periodically formed in the main body separately from each other, and the second dielectric member is filled in the
5 holes.

In the embodiment described above, the photonic crystal constituting the photonic crystal waveguide B has the second periodic structure 13A in which the third dielectric members 13 are separated from each other and the fourth dielectric
10 member 16 is filled in the space in the peripheries of the third dielectric members and surrounded by the substrates 11 and 12 and the sealing member 15. Alternatively, the second periodic structure may include a main body composed of the third dielectric member disposed in the region surrounded by
15 the substrates 11 and 12 and the sealing member 15, a plurality of holes are periodically formed in the main body separately from each other, and the fourth dielectric member is filled in the holes.

As described above, in accordance with the light
20 deflector of the present invention, the refraction angle of light incident from outside can be changed at high speed so that the direction of transmission of the light can be changed, and moreover, miniaturization is enabled.

In accordance with the optical switch of the present
25 invention, since the light deflector and the photonic crystal waveguide are included, the direction of transmitted light of a predetermined wavelength can be switched at high speed, and moreover, miniaturization is provided.